Application No. 10/697,647

Supplemental Amendment under 37 C.F.R. §1.111 dated January 28, 2005

Supplemental Response to the Office Action of October 19, 2004

Amendments to the Claims

Listing of claims:

This listing of claims replaces all prior versions and listings of claims in the application.

Claim 1 (Previously Presented): An electron beam apparatus comprising:

an electron gun for directing a plurality of primary electron beams onto a sample;

objective lens for forming an electric field to accelerate a plurality of secondary electron

beams emitted from said sample;

a separator for separating said plurality of secondary electron beams from a primary

optical system and for directing said plurality of secondary electron beams into a secondary

optical system for guiding to a detector outputting a detection signal of the secondary electron

beams; and

a deflector for deflecting said secondary electron beams in said secondary optical system,

wherein said deflector is controlled to deflect said plurality of secondary electron beams

synchronously with scanning of said plurality of primary electron beams, thereby preventing said

plurality of secondary electron beams from moving on said detector in response to the scanning

of said plurality of primary electron beams.

Claim 2 (Previously Presented): An electron beam apparatus according to claim 1,

wherein said plurality of primary electron beams and said plurality of secondary electron beams

are arranged in the vicinity of an optical axis.

Page 2 of 9

Supplemental Response to the Office Action of October 19, 2004

Claim 3 (Previously Presented): An electron beam apparatus according to claim 1,

further comprising:

a number of memories twice as much as a number of said detectors for storing digital

signals generated by A/D converting the detection signals; and

change-over switches disposed in front of and at a back of said memories, wherein the

detection signals from said detectors are input in one of said memories while the previous

detection signals stored in another of said memories are transmitted into a CPU or an image

processing unit.

Claim 4 (Previously Presented): An electron beam apparatus according to claim 1, further

comprising a plate having a plurality of apertures corresponding to said plurality of secondary

electron beams in front of said detector.

Claim 5 (Previously Presented): An electron beam apparatus comprising:

an electron gun having a cathode electrode, a Wehnelt electrode, and an anode electrode;

wherein said Wehnelt electrode comprises a first portion adjacent to said cathode

electrode and a second portion separated from said first portion, said first portion being finely

moveable in an x-direction, a y-direction, or a z-direction orthogonal to one another.

Page 3 of 9

Claim 6 (Previously Presented): An electron beam apparatus according to claim 5,

wherein said electron gun comprises a multi-emitter machined as a cathode including a plurality of emitters integrated thereon, a heater for heating said multi-emitter, a supporter for fixing said multi-emitter and said heater at given positions, a Wehnelt electrode, and a fine adjustment mechanism for finely adjusting the position of a portion of said Wehnelt electrode which is adjacent to said multi-emitter,

wherein said fine adjustment mechanism is configured to be able to finely adjust the position of said portion of said Wehnelt electrode in at least one of an x-direction, a y-direction, and a θ -direction in a plane parallel to a plane which includes said multi-emitter, and a tilt direction in a plane perpendicular to said plane.

Claim 7 (Original): An electron beam apparatus according to claim 6, wherein said fine adjustment mechanism in the θ -direction or tilt direction is disposed at a z-position substantially identical to said emitter.

Claim 8 (Original): An electron beam apparatus according to claim 6, wherein said portion of said Wehnelt electrode has a plurality of small holes corresponding to said plurality of emitters, and has a thickness of 200 µm or less only in the vicinity of said holes.

Claim 9 (Previously Presented): An electron beam apparatus according to claim 5, wherein said electron beam apparatus forms a plurality of narrowed electron beams from

emissions of said electron gun, scans a sample surface with said electron beams and detects secondary electron beams formed of secondary electrons emitted from scanned positions on said sample surface using a plurality of detectors.

Claim 10 (Previously Presented): An electron beam apparatus, comprising:

an electron gun for directing a plurality of primary electron beams onto a sample;

an objective lens for forming an electric field to accelerate a plurality of secondary electron beams emitted from said sample;

a separator for separating said plurality of secondary electron beams from a primary optical system;

a director for directing said plurality of secondary electron beams into a secondary optical system for guiding to a detector outputting a detection signal of the secondary electron beams; and

an ExB separator disposed between the objective lens and former stage lens in the primary optical system for separating said secondary electron beams.

Claim 11 (Previously Presented): An electron beam apparatus for directing a plurality of primary electron beams onto a sample, comprising:

an objective lens for forming an electric field to accelerate a plurality of secondary electron beams emitted from said sample;

Application No. 10/697,647 Supplemental Amendment under 37 C.F.R. §1.111 dated January 28, 2005 Supplemental Response to the Office Action of October 19, 2004

a separator for separating said plurality of secondary electron beams from a primary optical system; and

a director for directing said plurality of secondary electron beams into a secondary optical system for guiding to a detector outputting a detection signal of the secondary electron beams wherein a secondary electron image is focused around said separator.

Claim 12 (Cancelled)